

## IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF

HISAJI OYAKE, ET AL. : EXAMINER: ANGEBRANNDT, M.

SERIAL NO: 10/083,596

FILED: FEBRUARY 27, 2002 : GROUP ART UNIT: 1756

FOR: METHOD FOR PRODUCING PHOTORESIST MASTER FOR OPTICAL INFORMATION MEDIUM, AND METHOD FOR PRODUCING STAMPER FOR OPTICAL INFORMATION MEDIUM

## **AMENDMENT**

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Office Action dated October 23, 2003, please amend the aboveidentified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 5 of this paper.